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ISSUE CLASSIFICATION	
Class	Subclass

PATENT NUMBER

U.S. UTILITY Patent Application

AK SCANNED 5/23/2	O.I.P.E. NSA CH1	PATENT DATE
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APPLICATION NO. 09/901416	CONT/PRIOR	CLASS 438	SUBCLASS	ART UNIT 2812 2813	EXAMINER
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PLICANTS
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TITLE Dual hardmask process for the formation of copper/low-k interconnects

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PTO-2040
12/89[illegible]

<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS			CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims	Print Claim for O.G.
<input type="checkbox"/> The term of this patent subsequent to _____ (date) has been disclaimed.	_____ (Assistant Examiner) _____ (Date)			NOTICE OF ALLOWANCE MAILED	
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